# BiF/NF<sub>2</sub> Kinetics Studies: Mechanism and Conversion **Efficiency**

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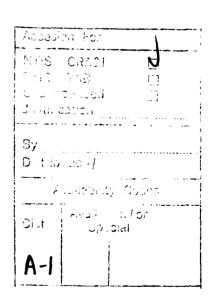
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19. ABSTRACT (Continue on reverse if necessary and identify by block number)  A series of experiments have been performed which examine the phenomenology of the formation of electronically excited $BiF(AO^+)$ in a photoinitiated reaction sequence involving $NF_2$ , $H_2$ , and $Bi$ atoms at 450 K. The experiments are based on time resolved, absolutely calibrated detection of three key reactive intermediates; $BiF(AO^+)$ , $NF(a^1\Delta)$ , and $Bi(^2D_{3/2})$ . The results of these measurements are not found to be consistent with the currently accepted formation mechanism. An alternative mechanism in which a metastable state of $BiF$ serves as an intermediate in the production of the A state is discussed in light of recent theoretical and experimental spectroscopic studies. Estimates are also made of the efficiency with which the electronic energy of $NF(a^1\Delta)$ is converted to $BiF(A\rightarrow X)$ photons, and the degree to which $Bi/BiF$ is repetitively pumped to the A state.									
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#### I. INTRODUCTION

Unraveling the complex kinetics of the  $NF(a^1\Delta)/BiF(A0^+)$  energy transfer system has been an ongoing concern of our laboratory for the past several years. The system is of particular interest because of its potential as a visible chemical laser. Of central importance in the evaluation of this potential is a knowledge of the chemical pathways leading to the formation of electronically excited  $DiF(A0^+)$ . This report describes the results of a series of recent experiments designed to investigate the nature of the  $BiF(A0^+)$  production mechanism and the efficiency with which the electronic energy of  $NF(a^1\Delta)$  is converted to  $BiF(A\to X)$  photons. We have examined the time behavior of three key species resulting from excimer laser initiated reactions of  $NF_2/Bi(CH_3)_3$ ,  $NF_2/Bi(CH_3)_3/H_2$ , and  $NF_2/Bi(CH_3)_3/HBr$  mixtures. An absolute calibration of the detection sensitivity for  $NF(a^1\Delta)$ ,  $BiF(A0^+)$ , and  $Bi(^2D_{3/2})$  was used to determine absolute number densities from time resolved emission, absorption, and laser induced fluorescence data.

Energy conservation dictates that at least two NF( $a^1\Delta$ ) molecules ( $T_e = 1.42 \text{ eV}$ ) are required to produce one BiF(A0<sup>+</sup>) ( $T_e = 2.85 \text{ eV}$ ). At low Bi and NF(a) densities, where the removal of BiF(A0<sup>+</sup>) is dominated by spontaneous emission (Ref. 1), the production of BiF(A0<sup>+</sup>) scales as [NF( $a^1\Delta$ )]<sup>2</sup>. This observed scaling has led to the proposal of two simple models to account for BiF(A0<sup>+</sup>) production:

Mechanism 1: 
$$NF(a^1\Delta) + BiF(X0^+) \rightarrow NF(X^3\Sigma^-) + BiF^*$$
 (1)

$$NF(a^{1}\Delta) + BiF^{*} \rightarrow NF(X^{3}\Sigma^{-}) + BiF(A0^{+})$$
 (2)

Mechanism 2: 
$$NF(a^1\Delta) + Bi(^4S) \rightarrow NF(X^3\Sigma^-) + Bi(^2D_{3/2})$$
 (3)

$$NF(a^{1}\Delta) + Bi(^{3}D_{3/2}) \rightarrow BiF(A0^{+}) + N(^{4}S)$$
 (4a)

$$\rightarrow$$
 BiF(a2,X1,X0<sup>+</sup>) + N(<sup>4</sup>S) (4b)

Processes (1) - (4) are not all inclusive of the reaction and quenching channels; however they are sufficient to illustrate the requirements of the pumping mechanism.

The identity of the BiF\* state invoked in Mechanism 1 has been a matter of considerable speculation. Based on the spectroscopic work of Jones and McLean (Ref. 2) and of Chakoo and Patel (Ref. 3), the state had been tentatively identified (in the nomenclature of Ref. 2) as BiF( $b0^+$ ) ( $T_e = 1.14 \text{ eV}$ ). In order for the successive energy transfers of Processes (1) and (2) to take place within kT of resonance, the receptor level of the BiF( $b0^+$ ) state would necessarily have to be v' = 4. Previous experiments (Ref. 4) showed that the yield of BiF( $A0^+$ ) was independent of Ar buffer gas pressure. This result was taken as an indication that a vibrationally excited intermediate (which could be collisionally relaxed) was not involved.

Accordingly, our attention has been focused on Mechanism 2, which does not involve a vibrationally excited state. Support for this mechanism also comes from the fact that Reaction (3) is well known (Ref. 5) and extremely efficient  $(k_3 = 2 \times 10^{-10} \text{ cm}^3/\text{molecule-sec})$ . The Bi( $^2D_{3/2}$ ) intermediate is optically metastable and collisionally inert with most partners. The purpose of the current experiments was to measure the time behavior of three important species for comparison with predictions based on Mechanism 2. However, as will be shown, under our experimental conditions, BiF( $A0^+$ ) formation by Mechanism 2 is not consistent with our data. Based on the results of these experiments and new spectroscopic information on BiF, reconsideration of other BiF( $A0^+$ ) production mechanisms is required.

#### II. EXPERIMENTAL

A diagram of the experimental apparatus is given in Fig. 1. Experiments were carried out in a heated stainless steel cell maintained at  $170^{\circ}$ C. Flow rates were determined using calibrated mass flowmeters (Tylan). A 10% mixture of  $N_2F_4$  in Ar was flowed through a quartz bulb kept at  $190^{\circ}$ C to ensure complete pyrolysis into NF<sub>2</sub>. Other reagents were flowed directly into the photolysis cell. A 249-nm KrF laser pulse was used to initiate reactions from NF<sub>2</sub>/Bi(CH<sub>3</sub>)<sub>3</sub>/Ar and NF<sub>2</sub>/H<sub>2</sub>/Bi(CH<sub>3</sub>)<sub>3</sub>/CO<sub>2</sub>/Ar mixtures, while a 193-nm ArF laser was used for mixtures containing NF<sub>2</sub>/HBr/Bi(CH<sub>3</sub>)<sub>3</sub>/CO<sub>2</sub>/Ar. The excimer laser was operated at repetition rates of 1-2 Hz to permit replacement of the gas mixture in the photolysis cell between laser shots. Both NF( $a^1\Delta$ ) and BiF( $A0^+$ ) were detected by time resolved emission using a thermoelectrically cooled GaAs photomultiplier tube (PMT) (RCA C31034) and an "S" response PMT (EMI 6256S), respectively. Narrow bandpass filters were employed to isolate the emission from the NF a-X (0.0) band at 874 nm and the BiF A-X (0.2) band at 457 nm. Three methods were used for Bi( $^2$ D<sub>3/2</sub>) detection:

- In some cases,  $Bi(^2D_{3/2})$  was monitored directly in emission by the  $^2D_{3/2}$   $^4S_{3/2}$  transition at 876 nm using an additional cooled GaAs PMT and narrow-band filter.
- A single-mode ri.ig dye laser (Coherent model CR-699-21) using Rhodamine 6G dye was intracavity frequency doubled to provide 0.5 3 mW of radiation near 300 nm with a bandwidth of 1 MHz. The dye laser was used to monitor Bi(<sup>2</sup>D<sub>3/2</sub>) using laser induced fluorescence (LIF) by pumping the Bi <sup>4</sup>P<sub>3/2</sub> ← <sup>2</sup>D<sub>3/2</sub> transition at 298.9 nm. The resulting Bi <sup>4</sup>P<sub>3/2</sub> → <sup>2</sup>D<sub>5/2</sub> fluorescence at 339.7 nm was detected using a second "S" response PMT (EMI 6256S) equipped with an 8-nm FWHM bandpass filter centered at 340 nm.
- In addition, Bi(<sup>2</sup>D<sub>3/2</sub>) was also observed by its absorption on the 7s <sup>4</sup>P<sub>3/2</sub> 6 <sup>3</sup> <sup>2</sup>D<sub>3/2</sub> transition. Light from a Bi hollow cathode lamp, collimated with a 10-cm focal lens, was directed longitudinally through the photolysis cell and focused on the slits of a 1/3 meter monochromator (McPherson 218). The Bi line emission was detected by a PMT (Hamamatsu R2658) mounted on the exit slit of the monochromator. The monochromator was operated with a spectral bandpass of 0.2 nm, adequate to resolve the Bi <sup>4</sup>P<sub>3/2</sub> ← <sup>2</sup>D<sub>3/2</sub> line from neighboring transitions. The Bi hollow cathode lamp was operated in a pulsed mode to provide sufficient intensity for time-resolved absorption measurements. Typically, the lamp pulse width was 500 μsec with a lamp current of 0.5 A during the pulse.

Emission, LIF, and absorption signals were acquired using a multichannel transient digitizer (LeCroy 2264) and stored with a laboratory computer (DEC LSI 11/73).

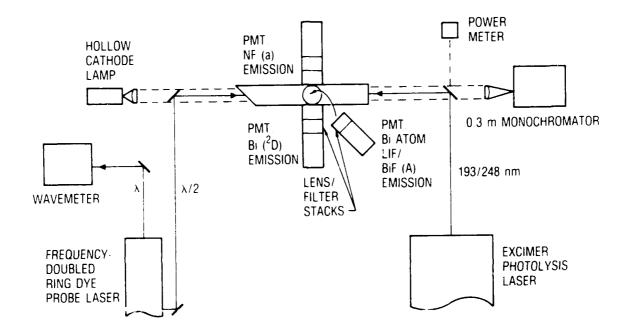


Fig. 1. Schematic Diagram of Experimental Apparatus.

#### III. ABSOLUTE CALIBRATION

In order to obtain a relative calibration of PMT detection sensitivity for the species of interest, it is necessary to determine several detection characteristics. These include filter transmission curves and the relative wavelength responsivity of the various photomultiplier tubes. Three different detectors were used. The response of each PMT viewing the same signal provided the basis for a relative calibration among the three. Overlap of the emission spectrum of each species with its associated filter transmission curve and oscillator strengths of the various transitions must be employed in order to relate the light intensity incident on each detector to the number density of a particular species. Absolute calibration was accomplished by employing NF a-X emission from a known concentration of NF( $a^1\Delta$ ).

Transmission curves of the bandpass filters were measured with a quartz halogen lamp and a 1/3 meter monochromator using Ne lines from a spectral lamp to provide wavelength calibration. Since each filter had a very narrow bandpass,  $\Delta\lambda < 1$  nm, spectral variations in the intensity of the lamp could be neglected. Convolution of the filter transmission curves and the emission spectra of each species enabled us to determine the fraction of light from each emission feature transmitted through the different filters: the "filter response" factor. Figure 2 shows filter transmission curves near 874 nm along with the NF(a<sup>1</sup> $\Delta$ ) and Bi(<sup>2</sup>D<sub>3/2</sub>) emission features. Also included in Fig. 2 is the BiF A-X filter transmission curve together with the pertinent part of the BiF A-X emission spectrum.

The relative wavelength response of one of the GaAs detectors was determined with a tungsten ribbon lamp, whose temperature was measured using an optical pyrometer. The ribbon lamp photon flux was calculated using a standard Planck blackbody function corrected by the emissivity of tungsten reported by Rutgers and DeVos (Ref. 6). Measurements were performed using each of the three filters to cover the three narrow wavelength regions that they defined. The relative intensity falling on the PMT photocathode was determined from a convolution of the modified blackbody function with the measured filter transmission curves. The fact that the measured response at the similar NF( $a^1\Delta$ ) and Bi( $^2D_{3/2}$ ) wavelengths (874.3 and 875.5 nm) was identical within experimental error and that the relative response at 874 and 457 nm agreed with previous measurements in this laboratory (Ref. 7) lends credence to our results. The relative detection sensitivity for each species was then obtained from the measured wavelength responsivity of the PMT, the "filter response" factor, and the Bi( $^2D_{3/2}$ ), BiF(AO+, v=0), and NF( $a^1\Delta$ ) radiative lifetimes (Refs. 8-10).

One GaAs PMT was calibrated as described above. Relative detection sensitivity of the other detectors was determined from the comparison of NF( $a^1\Delta$ ), Bi( $^2D_{3/2}$ ), and BiF A-X (6,2) emission signals resulting from KrF photolysis of identical NF<sub>2</sub>/Bi(CH<sub>3</sub>)<sub>3</sub>/Ar and Bi(CH<sub>3</sub>)<sub>3</sub>/Ar mixtures as the various filters were rotated among the different phototubes. Since these calibrations were performed in situ, variations in sensitivity due to detection geometry and collection efficiency are inherently included.

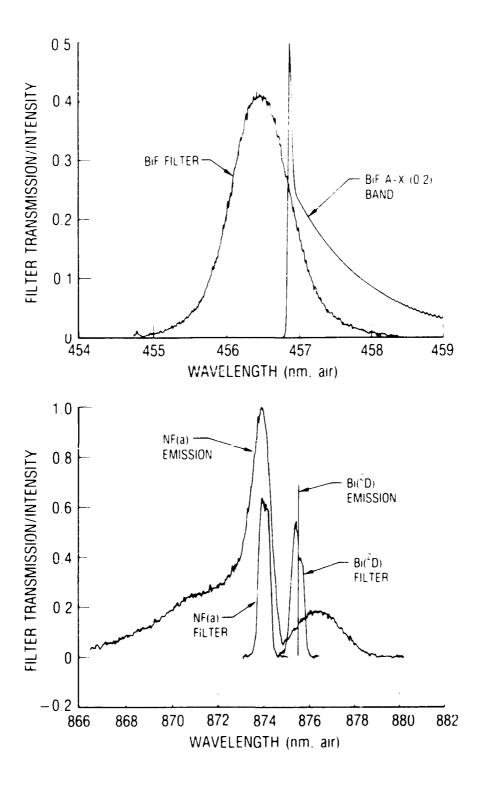


Fig. 2. Measured Filter Transmission Curves and Pertinent NF( $a^1\Delta$ ), Bi( $^2D_{3/2}$ ), and BiF(AO+) Emission Features.

Absolute calibration of the detection sensitivity for NF( $a^1\Delta$ ) was performed using NF( $a^1\Delta$ ) emission signals from both the 249-nm photolysis of NF2 and the reaction of H atoms, created by HBr photolysis at 193 nm, with NF2. The excimer laser beam profiles were determined from burn patterns, and the relative laser energy was measured using a Coherent model 212 power meter. Reported values for the NF2 (Refs. 11, 12) and HBr (Ref. 13) absorption cross sections at 249 and 193 nm, respectively, were used to calculate the NF2 and HBr photolysis fractions. We also performed our own measurement of the HBr absorption coefficient and reproduced the value given by Magnotta et al. (Ref. 13). The NF( $a^1\Delta$ ) photolysis quantum yield (Refs. 11, 12) and the NF( $a^1\Delta$ ) reaction branching ratio had both been previously determined (Refs. 10, 14). Thus, the NF( $a^1\Delta$ ) density could be calculated, and an absolute calibration was effected. The measurements of the NF( $a^1\Delta$ ) detection sensitivity from KrF laser photolysis of NF2 and from the 193-nm photolysis of HBr in NF2 differed by less than a factor of 2. Absolute detection sensitivities for Bi( $^2D_{3/2}$ ) and BiF( $A0^+$ ,  $v^i=0$ ) were then determined using the NF( $a^1\Delta$ ) result and the relative detection sensitivities described above.

The major contribution to the uncertainty in the absolute calibration stems from errors in the determination of the temperature of the tungsten ribbon lamp. The rather low operating temperature of 1700 K results in large errors in the calculated lamp flux at the BiF A-X (0,2) band wavelength for relatively small errors in the measured tungsten ribbon temperature. This primarily affects the determination of the relative wavelength response of the PMT at 860 and 457 nm. In addition, errors in the weak  $\mathrm{Bi}(^2\mathrm{D}_{3/2})$  ( $\tau$  = 31 msec) (Ref. 8) and NF( $\mathrm{a}^1\mathrm{a}$ ) ( $\tau$  = 5.5 sec) (Ref. 10) transition strengths are also important. Taking these and other factors into consideration, we estimate that errors in our absolutely calibrated data are on the order of a factor of 2 for  $\mathrm{Bi}(^2\mathrm{D}_{3/2})$  and NF( $\mathrm{a}^1\mathrm{a}$ ) data which occur at nearly adjacent wavelengths. An uncertainty of about a factor of 4 is estimated for the BiF(A0+) as a result of the error involved in the temperature determination of the tungsten ribbon. While these uncertainties are significant, they do not obviate the major points made in Section IV.

### IV. RESULTS AND DISCUSSION

As discussed previously, this series of experiments was originally conceived as a means of testing (albeit under a limited range of conditions) the validity of the proposed mechanism for  $BiF(A0^+)$  production. Our means of accomplishing this objective was to ascertain the time histories of the excited state intermediates  $Bi(^2D_{3/2})$ ,  $NF(a^1\Delta)$ , and  $BiF(A0^+)$ . This was to be done by recording time-resolved traces of their optical emission. This is a valid approach for those experiments in which the KrF photolysis of NF<sub>2</sub> is the predominant source of NF( $a^1\Delta$ ). However, when the photolysis was employed to initiate the H + NF<sub>2</sub> chemistry, the emission from the resulting NF( $a^1\Delta$  v' = 1) as sufficient to obscure  $Bi(^2D_{3/2})$  emission. It was therefore necessary to develop alternative methods of monitoring  $Bi(^2D_{3/2})$ .

### A. DETECTION OF Bi USING LASER-INDUCED FLUORESCENCE

Attempts to monitor  $\mathrm{Bi}(^2\mathrm{D}_{3/2})$  by pumping the  $^4\mathrm{P}_{1/2}$  –  $^2\mathrm{D}_{3/2}$  transition at 472.2 nm and observing  $^4\mathrm{P}_{1/2}$  –  $^4\mathrm{S}$  LIF at 306.8 nm proved to be complicated by optical pumping and radiation trapping effects. At higher single-mode dye laser powers ( $\simeq 300$  mW), an appreciable fraction of the  $\mathrm{Bi}(^2\mathrm{D}_{3/2})$  population was transferred to the  $^4\mathrm{P}_{1/2}$  state. The use of lower dye laser powers diminished the optical pumping effects. However, as a consequence of the very high oscillator strength of the 306.8-nm Bi transition (gf = 0.99) (Ref. 15) and high Bi  $^4\mathrm{S}$  ground state density, radiation trapping precluded the use of this Bi detection method. An alternative LIF detection scheme was therefore chosen. In this case, the time history of  $\mathrm{Bi}(^2\mathrm{D}_{3/2})$  was observed by exciting the  $^4\mathrm{P}_{3/2}$  –  $^2\mathrm{D}_{3/2}$  transition at 298.9 nm, with subsequent detection of  $^4\mathrm{P}_{3/2}$  –  $^2\mathrm{D}_{5/2}$  emission at 339.7 nm. Since only very modest laser fluences were employed ( $\sim 1$  mW), optical pumping of the  $^2\mathrm{D}_{3/2}$  state was avoided. Because only transitions between Bi excited states were involved, we observed no indication of radiation trapping.

Initial studies focused on the KrF laser photolysis of Bi(CH<sub>3</sub>)<sub>3</sub>/Ar mixtures where Bi( $^2D_{3/2}$ ) was simultaneously monitored by time resolved emission at 876 nm, in addition to time-resolved LIF. Figure 3 contains experimental Bi( $^2D_{3/2}$ ) traces resulting from both techniques. Clearly, the normalized Bi( $^2D_{3/2}$ ) time profiles in Fig. 3 do not decay at the same rate; the LIF profile decays some 20–30% faster than the 876-nm emission profile. A systematic study of the Bi( $^2D_{3/2}$ ) LIF was undertaken to obtain an explanation for this discrepancy.

The Bi( $^2D_{3/2}$ ) LIF was recorded as the Ar buffer gas density was varied by nearly an order of magnitude from  $1 \times 10^{17}$  to  $8 \times 10^{17}$  atoms/cm<sup>3</sup> while holding the initial Bi atom density constant. The Bi( $^2D_{3/2}$ ) LIF decay and amplitude remained constant. Similarly, the LIF decay and amplitude were invariant as the dye laser beam area was changed from 0.2 to 1.0 cm<sup>2</sup>. We may, therefore, concl. de that the effects of Bi atom diffusion are negligible for our experimental conditions.

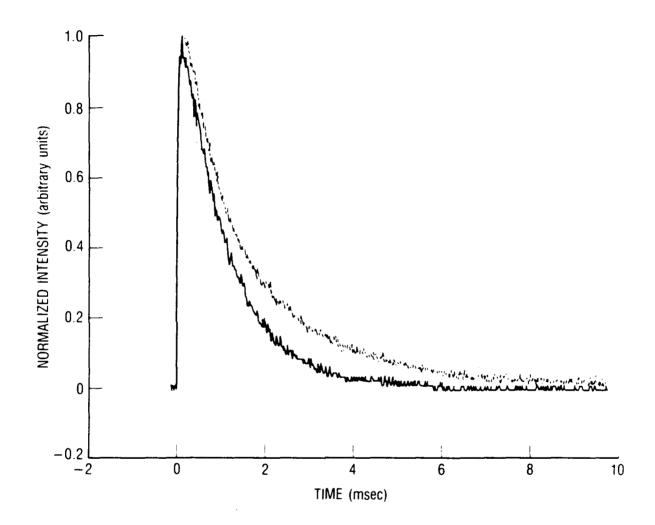


Fig. 3. Bi( $^2D_{3/2}$ ) Time Profiles from 249-nm Photolysis of Bi(CH<sub>3</sub>)<sub>3</sub> in Argon ([Ar] =  $2.7 \times 10^{17}$  atoms/cm<sup>3</sup>; [Bi(CH<sub>3</sub>/<sub>3</sub>] =  $1.6 \times 10^{13}$  molecules/cm<sup>3</sup>). The dotted curve is Bi( $^2D_{3/2}$ ) - Bi( $^4S$ ) emission, and the solid trace is the Bi $^4P_{3/2} \rightarrow ^2D_{5/2}$  laser induced fluorescence.

The  $\mathrm{Bi}(^2\mathrm{D}_{3/2})$  LIF behaves as expected as a function of the dye laser power. Plots of the LIF amplitudes and decay rates are shown in Fig. 4 for several dye laser powers. The maximum dye laser power delivered to the photolysis cell was about 0.7 mW. The amplitude scales linearly with the dye laser power and passes through the origin, and the LIF decay rate remains constant for the entire range studied. Thus, optical pumping effects are absent for the dye laser fluences used in this study. This is supported by the observation that the  $\mathrm{Bi}(^2\mathrm{D}_{3/2})$  emission decay rate is unaffected by the presence of the dye laser, contrary to the results of 472-nm LIF experiments.<sup>‡</sup>

The rate coefficient for the quenching of Bi(<sup>2</sup>D<sub>3/2</sub>) by Bi(CH<sub>3</sub>)<sub>3</sub> was measured using Bi(<sup>2</sup>D<sub>3/2</sub>) time profiles obtained from both Bi(<sup>2</sup>D<sub>3/2</sub>) emission and LIF. Experimental Bi(<sup>2</sup>D<sub>3/2</sub>) profiles were fit to a single exponential function, and decay rates are plotted against Bi(CH<sub>3</sub>)<sub>3</sub> density in Fig. 5. The slopes of both curves agree within our experimental uncertainty. We also note that the rate constants obtained here are in reasonable agreement with those reported in Ref. 16. The difference between the emission and LIF data in Fig. 5 lies in the values of the intercept. The emission data pass within experimental error through the reported (Ref. 8) Bi(<sup>2</sup>D<sub>3/2</sub>) Einstein A coefficient of 31.2 sec<sup>-1</sup>. However, the intercept of the LIF data is nearly six times larger. The reason for this effect remains unexplained.

## B. DETECTION OF BI USING ABSORPTION

Because of anomalous results obtained from our LIF experiments, we chose to verify the results of our  $Bi(^2D_{3/2})$  measurements by means of an absorption probe on the  $^4P_{3/2} \leftarrow ^2D_{3/2}$  Bi atom transition at 298.9 nm. This is the same transition which was employed as the pumping step of our LIF probe. Because the species of interest is atomic, its absorption cross section is quite large. As a result, this method proved to be sufficiently sensitive at the rather low number densities used in these experiments. Absorption measurements are inherently quantitative. Analysis of the resultant data is straightforward, and absolute values for  $Bi(^2D_{3/2})$  densities may be determined by way of our previous calibrations.

For these experiments we have employed a pulsed Bi hollow cathode lamp (HCL). The use of an HCL provides a stable and reproducible atomic line source whose features are sharp and relatively unperturbed by electric field effects and pressure broadening (Ref. 17). The lamp was operated in the pulsed mode in order to provide sufficient intensity on the time scale of the excited state lifetimes.

To obtain absolute number densities, it was first necessary to determine an absorption cross section for the  ${}^4P_{3/2} \leftarrow {}^2D_{3/2}$  Bi transition. This was accomplished by conducting a series of experiments in which varying densities of Bi(CH<sub>3</sub>)<sub>3</sub> were photolyzed at KrF wavelength. The resultant Bi( ${}^2D_{3/2}$ ) population was monitored in both emission and absorption. Source intensity in the absence of absorption (I<sub>0</sub>) was determined both with the gas mixture in the cell and the photolysis laser blocked and in the presence of the laser with the cell evacuated. Both methods gave identical values for I<sub>0</sub>, indicating that there was no appreciable attenuation due to the gas mixture. The background was taken before and after each concentration measurement to account for any drift

The observed  $Bi(^2D_{3/2})$  – <sup>4</sup>S <u>emission</u> decay rate increased with the 472-nm dye laser present due to optical pumping into the  $Bi(^4P_{1/2})$  which has a radiative lifetime of 7 nsec.

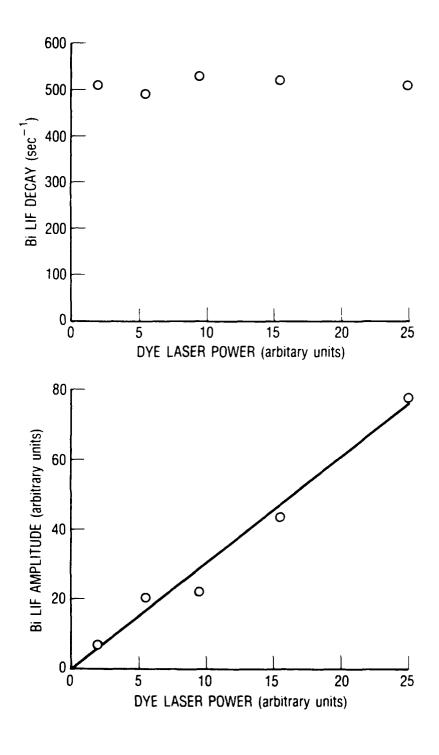


Fig. 4. Bi  $^4P_{3/2} \rightarrow ^2D_{5/2}$  Laser Induced Fluorescence as a Function of Dye Laser Power. Data are from the KrF laser photolysis of 7.5 × 10<sup>12</sup> molecules/cm<sup>3</sup> Bi(CH<sub>3</sub>)<sub>3</sub> in 2.6 × 10<sup>17</sup> atoms/cm<sup>3</sup> Ar. The upper part of the figure displays the decay rate behavior. The amplitude is shown in the lower part along with a linear fit constrained to pass through the origin. Decay rates and amplitudes are obtained from least-squares fits of timeresolved LIF data to a single exponential function.

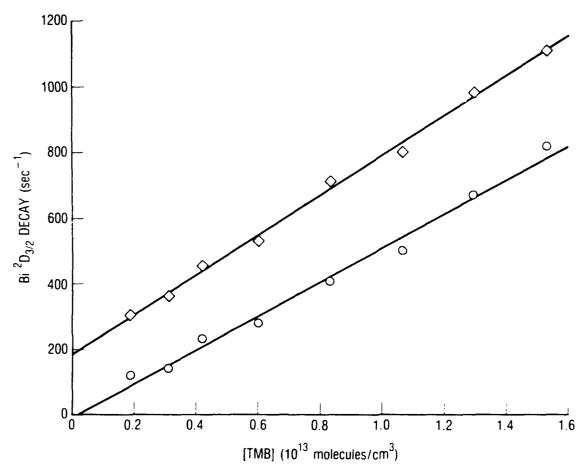


Fig. 5. Bi( $^2D_{3/2}$ ) Decay Rates as a Function of Bi(CH<sub>3</sub>)<sub>3</sub> Density from KrF Laser Photolysis. The Ar concentration was held constant at  $1.8 \times 10^{17}$  atoms/cm<sup>3</sup>. Single exponential least-squares fits to the data provided the decay rates plotted. Diamonds represent the Bi  $^4P_{3/2} \rightarrow ^2D_{5/2}$  LIF data, and Bi( $^2D_{3/2}$ ) emission data are given by the circles. Slopes of the solid lines, linear fits to the data, are  $6.1\pm1.0 \times 10^{-11}$  cm<sup>3</sup>/molecule-sec (diamonds) and  $5.2\pm0.9 \times 10^{-11}$  cm<sup>3</sup>/molecule-sec (circles).

in the HCL signal or degradation in the transmission of the cell windows caused by slow accumulation of Bi metal from the photolysis. According to the Beer-Lambert expression

$$\sigma = \ln(I_0/I)/\{[Bi(^2D_{3/2})] I\}$$
 (I)

where  $\sigma$  is the absorption cross section, I is the transmitted intensity, and l is the path length. Since we have absolutely calibrated the detection for Bi( $^2D_{3/2}$ ) emission as discussed above, the absorption cross section can be determined from the emission and absorption data. Figure 6 shows the results for a number of experimental runs. We measure a value of  $\sigma = 3.7 \pm 1.4 \times 10^{-14}$  cm<sup>2</sup>. This value is over two orders of magnitude smaller than the cross section calculated based on the Einstein A coefficient for the transition (Ref. 15). This may be an indication that the lamp is self-reversed on this transition. However, as long as the operating conditions of the lamp are maintained constant, the use of our experimentally obtained cross section is valid in evaluating the absorption data.

At higher Bi(CH<sub>3</sub>)<sub>3</sub> concentrations (>6  $\times$  10<sup>13</sup> molecules/cm<sup>3</sup>), we observe a discrepancy in the temporal behavior of the absorption data with respect to the emission data. As with the anomalous results of the LIF experiments, the reason for this is not clear. Therefore, care was taken to conduct our subsequent experiments using Bi(CH<sub>3</sub>)<sub>3</sub> densities below 5  $\times$  10<sup>13</sup> molecules/cm<sup>3</sup> where both absorption and emission data yielded identical results.

## C. KINETICS RESULTS

Experimental time profiles of  $Bi(^2D_{3/2})$ ,  $NF(a^1\Delta)$ , and  $BiF(A0^+)$  from the KrF laser initiation of  $NF_2/H_2/Bi(CH_3)_3/CO_2/Ar$  mixtures using  $Bi(^2D_{3/2})$  LIF and absorption are presented in Figs. 7 and 8, respectively. Note that the  $Bi(^2D_{3/2})$  profiles obtained by both techniques decay on the same timescale. Because it occurs well within the induction time for the formation of  $NF(a^1\Delta)$ , the rapid  $Bi(^2D_{3/2})$  decay can be primarily attributed to reaction with  $NF_2$ .

$$Bi(^{2}D_{3/2}) + NF_{2} \rightarrow BiF(X0^{+}) + NF(a^{1}\Delta)$$
 (5a)

$$\rightarrow BiF(XO^+, X1, a2) + NF(X^3\Sigma)$$
 (5b)

$$\rightarrow Bi(^4S) + NF_2 \tag{5c}$$

A second removal channel for Bi(2D<sub>3/2</sub>) is the reverse of Process (3), i.e.,

$$Bi(^{2}D_{3/2}) + NF(X^{3}\Sigma) \rightarrow Bi(^{4}S) + NF(a^{1}\Delta)$$
(6)

At the photolysis fluences employed ( $\sigma I = 0.02 - 0.03$ ), Process (6) is expected to make a lesser contribution to the observed decay than Process (5). In addition, NF(X<sup>3</sup> $\Sigma$ ) is itself removed by

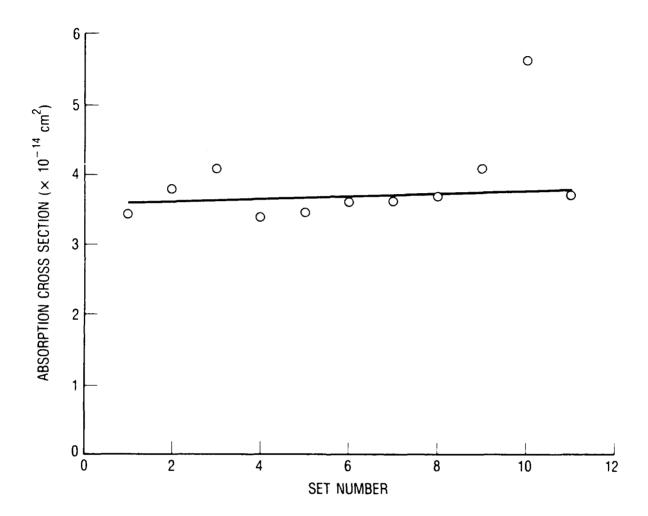


Fig. 6. Experimental Determinations of the Absorption Cross Section  $\sigma$  for the 7s  $^4P_{3/2} \leftarrow 6p^3 \, ^2D_{3/2}$  Bi Atom Transition at 298.99 nm. A value of  $\sigma = 3.7 \pm 1.4 \times 10^{-14}$  cm<sup>2</sup> was obtained. This is to be compared to a theoretical value of  $5 \times 10^{-12}$  cm<sup>2</sup> based on the oscillator strength of the transition.

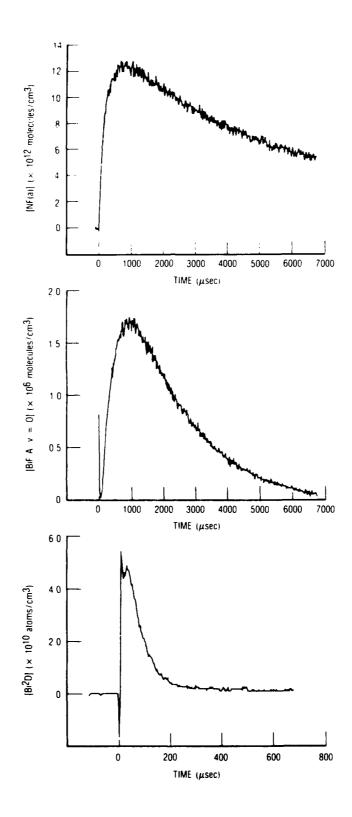


Fig. 7. Experimental NF( $a^1\Delta$ ), BiF( $A0^+$ ), and Bi( $^2D_{3/2}$ ) Time Profiles. Species densities were [NF<sub>2</sub>] = 1.5 × 10<sup>15</sup>, [Bi(CH<sub>3</sub>)<sub>3</sub>] = 2.0 × 10<sup>13</sup>, [H<sub>2</sub>] = 4.3 × 10<sup>14</sup>, [CO<sub>2</sub>] = 7.1 × 10<sup>16</sup>, and[Ar] = 1.1 × 10<sup>17</sup>. The cell temperature was 166°C. The KrF photolysis laser was operated at 2 Hz and delivered a flux of about 30 mJ/cm<sup>2</sup>. The traces are the average 25 laser shots. The Bi( $^2D_{3/2}$ ) trace was obtained from time-resolved LIF data. Note shorter time scale for the Bi( $^2D_{3/2}$ ) data.

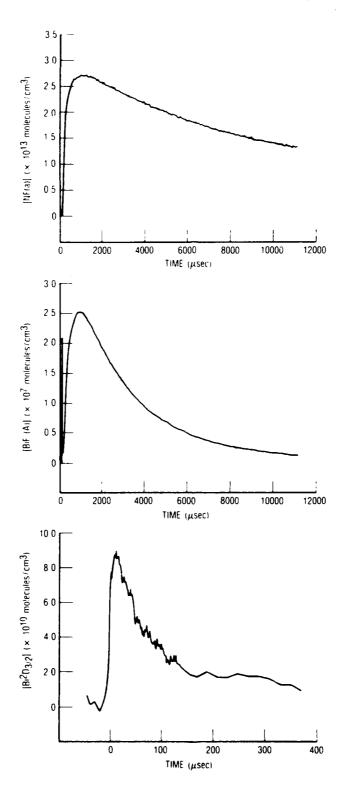


Fig. 8. Excited State Time Histories of NF( $a^1\Delta$ ), BiF(A0+), and Bi( $^2D_{3/2}$ ). The Bi( $^2D_{3/2}$ ) trace was obtained from time-resolved absorption data. Reagent concentrations were [NF<sub>2</sub>] = 1.5 ×  $10^{15}$ , [Bi(CH<sub>3</sub>)<sub>3</sub>] = 2.2 ×  $10^{13}$ , [H<sub>2</sub>] = 1.1 ×  $10^{15}$ , and [CO<sub>2</sub>] = 5.0 ×  $10^{17}$ . The cell was held at a total pressure of 8.25 torr with Ar and a temperature of 174°C. The KrF photolysis laser was operated at 2 Hz and delivered a flux of about 38 mJ/cm<sup>2</sup>. The traces are the average 100 laser shots. Note the shorter time scale for the Bi( $^2D_{3/2}$ ) data.

$$NF(X^{3}\Sigma) + NF_{2} \rightarrow N_{2}F_{2} + F \tag{7}$$

on a relatively rapid ( $\sim$ 350 µsec) timescale (Ref. 18). Recent measurements in this laboratory have determined that  $k_5 \le 1.2 \times 10^{-11}$  cm<sup>3</sup>/molecule-sec. If we take  $k_6 = 1.7 \times 10^{-10}$  (determined according to detailed balance from  $k_1 = 1.8 \times 10^{-10}$ ),  $k_7 = 2.0 \times 10^{-12}$ ,  $[NF(X^3\Sigma)]_0 = 3.2 \times 10^{13}$ , and  $[NF_2] = 1.4 \times 10^{15}$ , then the Bi( $^2D_{3/2}$ ) decay rates are reasonably well modeled by consideration of Processes (5), (6), and (7) alone.

Under our conditions, the predominant manner of removal of BiF(A0<sup>+</sup>) is spontaneous emission,

$$BiF(A0^+) \rightarrow BiF(X0^+) + h\nu$$
 (8)

Proceeding on the assumption that Mechanism 2 is dominant and conditions are in steady state, on the basis of Processes (3), (4), and (8) one can conclude that

$$k_4 = A_{BiF}[BiF(A0^+)]/[Bi(^2D_{3/2})][NF(a^1\Delta)]$$
 (II)

where  $k_4$  is the rate constant for Process (4) and  $A_{BiF}$  is the BiF (A $\rightarrow$ X) Einstein A coefficient. Steady state conditions are attained when the rate of change of [NF( $a^1\Delta$ )] and [Bi( $^2D_{3/2}$ )] is small compared to the radiative loss BiF(A0+). For these experiments, this condition was met in all cases. Thus, if BiF(A0+) is formed primarily by Mechanism 2, one would expect plots constructed from BiF(A0+), Bi( $^2D_{3/2}$ ), and NF( $a^1\Delta$ ) experimental time profiles using Eq. (II) to have a constant magnitude equal to  $k_4$ . Figure 9 presents a plot of Eq. (II) for the data in Fig. 8 at early times. This plot does not reach a constant value, but rather continues to increase with time. Clearly this result is in conflict with Eq. II. Either the assumption of a steady-state condition is not justified, or else Mechanism 2 as written is not the principal method of BiF(A0+) production under our conditions.

A kinetic model developed by Herbelin<sup>†</sup> was used to calculate  $Bi(^2D_{3/2})$ ,  $NF(a^1\Delta)$ , and  $BiF(A0^+)$  time profiles using the isothermal NIST ACUCHEM numerical modeling code (Ref. 19). The initial conditions employed were identical to the experimental conditions in Fig. 8. The sole  $BiF(A0^+)$  production step in this model is the  $Bi(^2D_{3/2}) + NF(a^1\Delta)$  reaction, and the predominant  $BiF(A0^+)$  removal is radiative. The reactions and rate coefficients used in this model are presented in the appendix. Figure 10 shows a steady-state plot suggested by Eq. (II) calculated with this model for the same time frame as portrayed in Fig. 9. This plot rapidly reaches a constant value which is in good agreement with the value of  $k_4$  (7.8 × 10<sup>-11</sup> molecule/cm<sup>3</sup>-sec) input into the calculations. Thus, a steady-state assumption is valid, even when applied to a more detailed kinetic analysis of this system.

It is therefore necessary to question the validity of the mechanism. The BiF(A0<sup>+</sup>) time behavior portrayed in Figs. 7 and 8 is not consistent with Mechanism 2. According to Reactions (3)

<sup>†</sup> J. M. Herbelin, private communication, The Aerospace Corporation, El Segundo, CA.

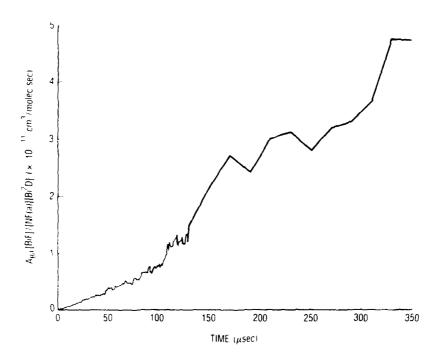


Fig. 9. Plot of Eq. (II) Constructed from the Absolute Data Presented in Fig. 8. The data from BiF( $A0^+$ ) used in this plot have had the scattered-light spike subtracted; an extrapolation from the remaining data was used for  $t < 30~\mu sec$ .

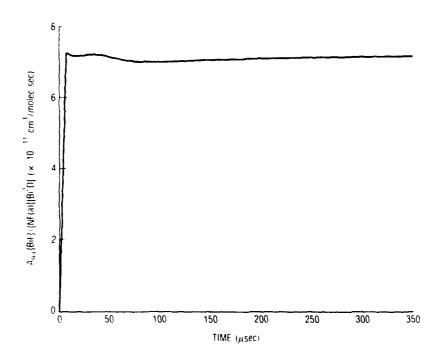


Fig. 10. Steady-State Plot Suggested by Eq. (II) Calculated Using the Kinetic Model Presented in the Appendix. The initial conditions are the same as for Fig. 8.

and (4), and Process (8), the peak concentration of BiF(A0<sup>+</sup>) should occur when the Bi( $^2D_{3/2}$ ) and NF( $a^1\Delta$ ) densities cross. Further, the BiF(A0<sup>+</sup>) density should fall off rapidly as Bi( $^2D_{3/2}$ ) decreases. Bi( $^2D_{3/2}$ ) does appear to reach a steady-state concentration at long times (> 200 µsec) but at a level that is at the lower limit of our dynamic range for these measurements. The significance of this long time behavior is uncertain. It may well represent establishment of an equilibrium with NF( $a^1\Delta$ ). Whether it is also in equilibrium with BiF(A0<sup>+</sup>) by Reaction (4a) or suppressed by means of Processes such as (4b) and (5) is impossible to determine within the context of these experiments. The following conclusions may be drawn, however:

- At the densities employed here,  $Bi(^2D_{3/2})$  is formed directly during the photolysis pulse and by cascading from higher lying states;
- Bi(2D<sub>3/2</sub>) is efficiently removed, probably by reactive collisions with NF<sub>2</sub>;
- Bi( ${}^2D_{3/2}$ ) does appear to reach a steady-state density in equilibrium with NF( $a^1\Delta$ ) at relatively long times, but at a level far below that which modeling predicts;
- Bi(<sup>2</sup>D<sub>3/2</sub>) does not display a temporal behavior that is compatible with the production of BiF(A0<sup>+</sup>) by Process (4a).

Hence, we conclude that BiF(A0<sup>+</sup>) formation under these conditions cannot be accounted for solely by Mechanism 2.

Balasubramanian has published a theoretical study of the low-lying electronic states of BiF (Ref. 20). More recently, Vervloet et al. have analyzed experimental FTIR spectra of BiF which fixed  $T_e$  for the X1 state at a significantly higher value than we had estimated earlier (Ref. 4). This assignment appears to substantiate the general features calculated by Balasubramanian. In particular, three of the four lowest lying states arising from the  $\sigma^2 \pi^4 \pi^{*2}$  configuration appear to be determined. These assignments are presented in a revised potential energy diagram in Fig. 11. Since all of Balasubramanian's calculated term values appear to be high by 2000 to 3000 cm<sup>-1</sup>, it is not unreasonable to assume that the a2 state is located in the region of 11500 to 12500 cm<sup>-1</sup>. If this is the case, an argument can be made that the BiF\* state of Mechanism 1 is actually the a2 state. The substantially higher electronic term value of the a2 state (in comparison to that of the b0+ state suggested by Ref. 2) removes the constraint of invoking a vibrationally excited intermediate. This in turn leaves our previous conclusions (Ref. 4) open for reassessment. Our current results lead us to believe that some variation of Mechanism 1 must be the operative pathway to BiF(A0+) production. Certainly Process (2) must be the final step; however, there is no evidence to preclude the possibility of such processes as

$$NF(a^1\Delta) + BiF(X0^+) \rightarrow NF(X^3\Sigma) + BiF(X1)$$
 (9a)

$$NF(a^{1}\Delta) + BiF(X1) \rightarrow NF(X^{3}\Sigma) + BiF(a2)$$
 (9b)

contributing to the overall production of the intermediate a2 state.

<sup>\*</sup>M. Vervloet, Herzberg Institute of Astrophysics, National Research Council of Canada, Ottawa, Canada, private communication.

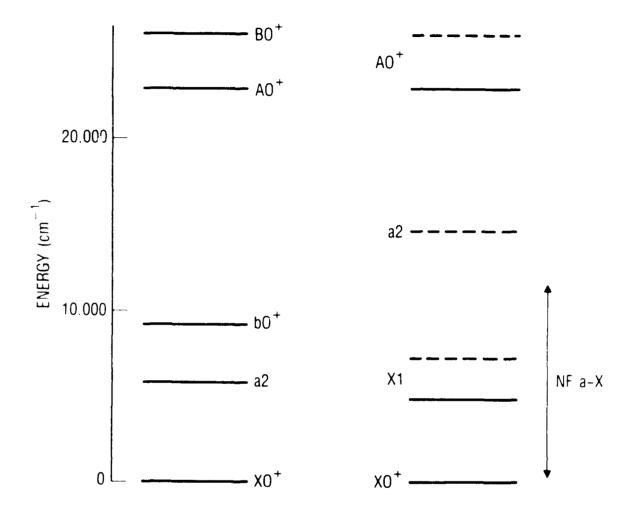


Fig. 11. Zero-Point Energies of the Lowest Lying States of BiF According to Ref. 2 (on the left) and the More Recent Assignment of Ref. 20 (on the right). The energy of NF(a-X) is also indicated. The diagram on the right uses dashed lines to indicate theoretical assignments and solid lines for states that have been experimentally observed.

We have not yet specified the origin of BiF(X0<sup>+</sup>) in Mechanism 1. Under the conditions of our experiments, the NF<sub>2</sub> density is in substantial excess. The NF-F and Bi-F bond energies were thought to be comparable; however, analysis of recent spectroscopic evidence (Ref. 21) suggests a BiF(X) bond energy of 100 kcal/mol. Thus, the most plausible source of ground state BiF is

$$Bi(^{4}S_{3/2}) + NF_{2} \rightarrow BiF(X0^{+}) + NF(X^{3}\Sigma)$$
 (10)

In addition, processes such as Reactions (4b) and (5b) may also contribute  $BiF(A0^+)$  formation in the system by channeling excited state intermediates into the production cycle. The short radiative lifetime of the  $A0^+$  state quickly leads to an equilibrium concentration of ground state BiF. We discount Reaction (5a) as being a major source of  $BiF(X0^+)$  on the basis of experimental data (Ref. 4) which show time histories of  $BiF(X0^+)$  that rise with time constants on the order of 100 to 150  $\mu$ sec. At the concentrations of  $NF_2$  employed in those experiments ( $10^{16}$  molecules/cm<sup>3</sup>), our rate for  $k_5$  would dictate rise times on the order of 5 to 10  $\mu$ sec. These observations are confirmed qualitatively by modeling calculation with the ACUCHEM and NEST codes.

It is of interest to consider the total number of BiF A-X photons emitted as a function of initial conditions. When examined with respect to the NF( $a^1\Delta$ ) density, such a quantity leads to a better understanding of the global efficiency of this system since it is directly related to how the chemical energy stored in NF( $a^1\Delta$ ) is converted into BiF A-X photons. Energy considerations dictate that at least two NF( $a^1\Delta$ ) molecules are required for the production of a single BiF A-X photon. However, processes such as electronic quenching of NF( $a^1\Delta$ ) or BiF( $A^0$ ) and NF( $a^1\Delta$ ) reactions with Bi(CH<sub>3</sub>)<sub>3</sub> will serve to limit the efficiency. The extent to which Bi atoms are recycled through the reaction system can be estimated from the initial Bi atom density resulting from the multiphoton Bi(CH<sub>3</sub>)<sub>3</sub> photolysis.

The absolute number of NF( $a^1\Delta$ ) molecules is constrained by the initial H<sub>2</sub> density under conditions where [NF<sub>2</sub>]<sub>0</sub> >> [H<sub>2</sub>]<sub>0</sub>. If [F]<sub>0</sub> > [H<sub>2</sub>]<sub>0</sub>, one will see [NF( $a^1\Delta$ )]max  $\leq$  0.9 [H<sub>2</sub>]<sub>0</sub>. If [F]<sub>0</sub> < [H<sub>2</sub>]<sub>0</sub>, the NF<sub>2</sub>/H<sub>2</sub> chain will run and [NF( $a^1\Delta$ )]max = C([F]<sub>0</sub> + [NF(X<sup>3</sup>Σ<sup>-</sup>)]), as discussed in Ref. 11. In this latter case, it is a bit more difficult to quantify the total NF( $a^1\Delta$ ) produced. The total number of BiF A-X photons is relatively easy to measure.

To minimize the effect of NF( $a^1\Delta$ ) reactions with Bi(CH<sub>3</sub>)<sub>3</sub>, a series of experiments were performed with NF( $a^1\Delta$ ) densities an order of magnitude larger than [Bi(CH<sub>3</sub>)<sub>3</sub>]. The total BiF A-X photon emission is calculated using our BiF A-X (v'=0, v''=2) emission data and the A-X (0,2) Franck-Condon factor (Ref. 2). The BiF(A) state was assumed to be in vibrational equilibrium at our operating temperature of 440 K. The photodissociation dynamics of Bi(CH<sub>3</sub>)<sub>3</sub> are unknown. However, bond strength considerations (Ref. 22) show that a KrF photon has sufficient energy to break all the Bi-CH<sub>3</sub> bonds and produce a Bi atom in its ground state. Production of excited Bi requires at least two KrF photons. Hence, an upper limit of the initial Bi atomic densities can be obtained from the Bi(CH<sub>3</sub>)<sub>3</sub> absorption cross section at 249 nm (Ref. 16) and the KrF flux. The results are presented in Table 1. The maximum BiF A-X photon production efficiency is on the order of 4%, where 100% efficiency would result in the production of one BiF A-X photon for every two NF( $a^1\Delta$ ) molecules in the system. It may also be noted that about two BiF A-X photons result for each [Bi]<sub>0</sub>. Thus we observe evidence of repetitive pumping of Bi (either as BiF or in the atomic form). Our earlier date (Ref. 4) demonstrated a finite appearance time for ground

state Bi <sup>4</sup>S atoms upon KrF photolysis of Bi(CH<sub>3</sub>)<sub>3</sub>. This suggests that the photolysis results in mostly excited Bi and therefore requires at least two photons. If this is the case, our estimate of [Bi]<sub>0</sub> will be low, and both conversion efficiency and the extent of recycling will be underestimated. On the other hand, multiple reactions with Bi(CH<sub>3</sub>)<sub>3</sub> may introduce additional Bi/BiF into the system at times that are long with respect to the initial photolysis pulse. Note that these observations are general in nature. They do not depend on a knowledge of the production mechanism of BiF(A0<sup>+</sup>).

Accurate knowledge of the BiF(A0<sup>+</sup>) formation mechanism is necessary in order to effectively evaluate the efficiency of the system. There are certain loss processes, however, that would be common to either route. The most significant among these are

$$NF(a^1\Delta) + NF(a^1\Delta) \rightarrow N_2 + 2F$$
 (11)

$$NF(a^1\Delta) + Bi(CH_3)_3 \rightarrow NF(X^3\Sigma^-) + Bi(CH_3)_3$$
 (12a)

It is clear, from the data taken on all approaches to BiF(A0<sup>+</sup>) scaling, that the energy extraction efficiency improves as precursor species such as NF<sub>2</sub> or Bi(CH<sub>3</sub>)<sub>3</sub> (at constant [Bi]) are reduced with respect to NF(a<sup>1</sup> $\Delta$ ).<sup>7</sup> This is to be expected for either mechanism. The other processes that lead to a lower efficiency will be those that remove the BiF(A0<sup>+</sup>) precursor [i.e., Bi(<sup>2</sup>D<sub>3/2</sub>) or BiF(a2)] or those that represent poor branching ratios (e.g., k<sub>4a</sub> < < k<sub>4b</sub> for Mechanism 2).

Table 1. Total Integrated BiF(A) Photon Emission

Run No.	$[NF(a)]_0^a$	[Bi] <sup>b</sup>	Total BiF A-X Photons <sup>c</sup>
1	$1.9 \times 10^{14}$	$\leq 1.4 \times 10^{12}$	$2.2 \times 10^{12}$
2	$2.5\times10^{14}$	$\leq 1.5 \times 10^{12}$	$3.6 \times 10^{12}$
3	$1.5\times10^{14}$	$\leq 1.5 \times 10^{12}$	$1.5 \times 10^{12}$
4	$2.3\times10^{14}$	$\leq 6.8 \times 10^{11}$	$1.7 \times 10^{12}$
5	$1.7\times10^{14}$	$\leq 2.8 \times 10^{12}$	$3.5 \times 10^{12}$

<sup>&</sup>lt;sup>a</sup>Units of molecules/cm<sup>3</sup>.

<sup>&</sup>lt;sup>b</sup>Units of atoms/cm<sup>3</sup>. Upper limits using Bi(CH<sub>3</sub>)<sub>3</sub> absorption cross section (see text).

<sup>&</sup>lt;sup>c</sup>Units of photons/cm<sup>3</sup>.

#### V. CONCLUSIONS

Time profiles of BiF(A0<sup>+</sup>), Bi( $^2$ D<sub>3/2</sub>), and NF(a<sup>1</sup> $\Delta$ ) were monitored following KrF laser initiation of NF<sub>2</sub>/H<sub>2</sub>/Bi(CH<sub>3</sub>)<sub>3</sub>/Ar/CO<sub>2</sub> mixtures. Detection of all three species was calibrated absolutely to allow quantitative measurements of transient number densities to be made. For all conditions employed, the observed BiF(A0<sup>+</sup>) and Bi( $^2$ D<sub>3/2</sub>) time behavior was not consistent with the currently accepted mechanism for the production of BiF(A0<sup>+</sup>). While much work has already been done, more work on this system is needed in order to provide a more complete understanding of reactions leading to BiF(A0<sup>+</sup>). In particular, spectroscopic characterization of the low lying BiF electronic states is necessary so that their role in the kinetics of this system can be fully evaluated. The relaxation and removal processes involving the BiF ground state must be studied before the mass efficiency and operating characteristics of this potential laser can be effectively judged.

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## APPENDIX: KINETIC MODELa

## NF<sub>2</sub> REACTIONS

Reaction			Rate Constant <sup>b</sup>
F + H <sub>2</sub>	<b>→</b>	HF + H	$3.7 \times 10^{-11}$
$H + NF_2$	<b>→</b>	HF + NF(a)	$1.3 \times 10^{-11}$
$H + NF_2$	<b>→</b>	HF + NF(b)	$2.8 \times 10^{-13}$
$H + NF_2$	<b>→</b>	HF + NF(X)	$1.0\times10^{-12}$
H + NF(a)	<b>→</b>	HF + N	$1.26 \times 10^{-11}$

## NF REACTIONS

Reaction			Rate Constant <sup>b</sup>
N + NF(a)		$N_2 + F$	$3.0 \times 10^{-11}$
NF(X) + NF(X)	<b>→</b>	$N_2 + F + F$	$2.0 \times 10^{-12}$
NF(a) + NF(a)	<b>-</b>	$N_2 + F + F$	$2.0 \times 10^{-12}$
NF(X) + NF(a)	<b>→</b>	$N_2 + F + F$	$2.0 \times 10^{-12}$
NF(a) + Ar		NF(X) + Ar	$2.7 \times 10^{-16}$
$N + NF_2$	<b>→</b>	NF(X) + NF(X)	$4.6 \times 10^{-12}$
$NF(X) + NF_2$		$F + N_2F_2$	$2.4 \times 10^{-12}$
$NF(a) + NF_2$	<b>→</b>	$F + N_2F_2$	$2.7\times10^{-16}$

<sup>&</sup>lt;sup>a</sup>This kinetic rate package is a working version of an ongoing effort to accurately model the chemistry of the NF/BiF system. It is presented to demonstrate the applicability of the steady-state assumption under the premise that Mechanism 2 is operative. It does not represent the most current version that the model has assumed. The authors are indebted to J. M. Herbelin for his permission to include it here.

bcm³/molecule-sec

# NF(a)/Bi<sup>4</sup>S)/BiF REACTIONS

Reaction			Rate Constant <sup>a</sup>
$NF(a) + Bi(^4S)$		$NF(X) + Bi(^2D)$	$1.9 \times 10^{-10}$
$NF(X) + Bi(^2D)$	<b>→</b>	$NF(a) + Bi(^4S)$	$1.9\times10^{-10}$
$NF(a) + Bi(^2D)$	<b>→</b>	N + BiF(A)	$7.80 \times 10^{-11}$
NF(a) + BiF(A)	<b>→</b>	$N + BiF_2$	$5\times10^{-10}$
BiF(A)	<b>→</b>	$BiF(X) + h\nu$	$^{\mathrm{b}}7 \times 10^{\mathrm{5}}$
BiF(A) + Ar	<b>→</b>	BiF(X) + Ar	$4.5\times10^{-13}$
BiF(X) + H	<b>→</b>	$Bi(^4S) + HF$	$4.0\times10^{-11}$
BiF(X) + NF(a)	<b>→</b>	$Bi(^4S) + NF_2$	$1.2\times10^{-10}$
BiF(X) + NF(X)	<b>→</b>	$Bi(^4S) + NF_2$	$1.2\times10^{-10}$

# Bi/NF<sub>2</sub> REACTIONS

Reaction	Rate Constant <sup>a</sup>		
$Bi(^4S) + NF_2$		BiF(X) + NF(X)	$5.0\times10^{-12}$
$Bi(^2D) + NF_2$		BiF(a) + NF(X)	$\leq 1.2 \times 10^{-11}$
$BiF(X) + NF_2$	+	$BiF_2 + NF(X)$	$5.0\times10^{-14}$
BiF <sub>2</sub> + Bi	<b>→</b>	BiF(X) + BiF(X)	$5 \times 10^{-12}$

<sup>&</sup>lt;sup>a</sup>cm<sup>3</sup>/molecule-sec

b<sub>sec-1</sub>

# Bi(CH₃)₃ DISSOCIATION PROCESSES

Reaction			Rate Constant <sup>a</sup>
$NF(a) + Bi(CH_3)_3$	<b>→</b>	$NF(X) + Bi(CH_3)_3^*$	$2.7 \times 10^{-11}$
$NF(a) + Bi(CH_3)_2$	<b>→</b>	$NF(X) + Bi(CH_3)_2^*$	$2.7 \times 10^{-11}$
$NF(a) + BiCH_3$	<b>→</b>	$NF(X) + BiCH_3*$	$2.7 \times 10^{-11}$
$NF(a) + Bi(CH_3)_3*$	<b>→</b>	$Bi(CH_3)_3^{**} + NF(X)$	$2.7 \times 10^{-11}$
$NF(a) + Bi(CH_3)_2^*$	<b>→</b>	$NF(X) + Bi(CH_3)_2^{**}$	$2.7 \times 10^{-11}$
Bi(CH <sub>3</sub> ) <sub>3</sub> *	<b>→</b>	$Bi(CH_3)_2 + CH_3$	$^{\mathrm{b}}2.7 \times 10^{4}$
Bi(CH <sub>3</sub> ) <sub>2</sub> *		BiCH <sub>3</sub> + CH <sub>3</sub>	$^{\mathrm{b}}1.9 \times 10^{7}$
Bi(CH <sub>3</sub> )*	<b>→</b>	$Bi(^4S) + CH_3$	$^{\rm b}2.8 \times 10^{12}$
Bi(CH <sub>3</sub> ) <sub>3</sub> *	<b>→</b>	$Bi(CH_3)_2^* + CH_3$	$^{\mathrm{b}}4.7 \times 10^{7}$
Bi(CH <sub>3</sub> ) <sub>2</sub> **	<b>→</b>	BiCH <sub>3</sub> * + CH <sub>3</sub>	$^{\rm b}2.26 \times 10^{10}$
Bi(CH <sub>3</sub> )	<b>→</b>	$Bi(^4S) + CH_3$	$b_5 \times 10^5$
Bi(CH <sub>3</sub> ) <sub>3</sub> ** + Ar	<b>→</b>	$Bi(CH_3)_3^* + Ar$	$4.0 \times 10^{-14}$
BiCH <sub>3</sub> ) <sub>3</sub> * + Ar	<b>→</b>	$Bi(CH_3)_3 + Ar$	$4.0 \times 10^{-14}$
Bi(CH <sub>3</sub> ) <sub>2</sub> ** + Ar	<b>→</b>	$Bi(CH_3)_2^* + Ar$	$4.0 \times 10^{-14}$
$Bi(CH_3)_2^* + Ar$	<b>→</b>	Bi(CH <sub>3)2</sub> + Ar	$4.0 \times 10^{-14}$

<sup>&</sup>lt;sup>a</sup>cm<sup>3</sup>/molecule-sec

 $b_{\text{sec}^{-1}}$ 

# Bi(2D) QUENCHING REACTIONS

Reaction			Rate Constant <sup>a</sup>
$Bi(^2D) + H_2$		$Bi(^4S) + H_2$	$2.0 \times 10^{-14}$
$Bi(^2D) + CH_3$	<b>→</b>	$Bi(^4S) + CH_3$	$2.6\times10^{-10}$
$Bi(^2D) + Bi(CH_3)_3$	<b>→</b>	$Bi(^4S) + Bi(CH_3)^{**}$	$7.7 \times 10^{-11}$
$Bi(^2D) + Bi(CH_3)_2$	<b>→</b>	$Bi(^4S) + Bi(CH_3)_2^*$	$7.7 \times 10^{-11}$
$Bi(^2D) + BiCH_3$	<b>→</b>	$Bi(^4S) + BiCH_3^*$	$7.7 \times 10^{-11}$

# METHYL REACTIONS

Reaction			Rate Constant <sup>a</sup>
$CH_3 + NF_2$	<b>→</b>	CH <sub>3</sub> NF <sub>2</sub>	$2.0 \times 10^{-12}$
$CH_3 + CH_3$	<b>→</b>	$C_2H_6$	$4.0 \times 10^{-11}$
$CH_3 + NF(a)$	<b>→</b>	CN + HF	$2.60 \times 10^{-10}$
$CH_3 + NF(X)$	<b>→</b>	$CN + H_2$	$2.6 \times 10^{-10}$
$H + CH_3$	<b>→</b>	CH <sub>4</sub>	$6.0 \times 10^{-11}$

<sup>&</sup>lt;sup>a</sup>cm<sup>3</sup>/molecule-sec

# FLUORINE ATOM SIDE REACTIONS

Reaction			Rate Constant <sup>a</sup>
F + CH <sub>4</sub>	<b>→</b>	HF + CH <sub>3</sub>	$1.3 \times 10^{-10}$
$F + Bi(CH_3)_3$	<b>→</b>	Bi(CH <sub>3</sub> ) <sub>2</sub> + products	$1\times10^{-10}$
$F + Bi(CH_3)_3^*$	<b>→</b>	Bi(CH <sub>3</sub> ) <sub>2</sub> + products	$1\times10^{-10}$
$F + Bi(CH_3)_3**$	<b>→</b>	$Bi(CH_3)_2 + products$	$1\times10^{-10}$
$F + Bi(CH_3)_2$	<b>→</b>	BiCH <sub>3</sub> + products	$1\times 10^{-10}$
$F + Bi(CH_3)_2^*$	· →	BiCH <sub>3</sub> + products	$1 \times 10^{-10}$
$F + Bi(CH_3)_2^{**}$	<b>→</b>	BiCH <sub>3</sub> + products	$1\times10^{-10}$
F + BiCH <sub>3</sub>	<b>→</b>	BiF(X) + products	$1\times 10^{-10}$

<sup>&</sup>lt;sup>a</sup>cm<sup>3</sup>/molecule-sec

#### LABORATORY OPERATIONS

The Aerospace Corporation functions as an "architect-engineer" for national security projects, specializing in advanced military space systems. Providing research support, the corporation's Laboratory Operations conducts experimental and theoretical investigations that focus on the application of scientific and technical advances to such systems. Vital to the success of these investigations is the technical staff's wide-ranging expertise and its ability to stay current with new developments. This expertise is enhanced by a research program aimed at dealing with the many problems associated with rapidly evolving space systems. Contributing their capabilities to the research effort are these individual laboratories:

Aerophysics Laboratory: Launch vehicle and reentry fluid mechanics, heat transfer and flight dynamics; chemical and electric propulsion, propellant chemistry, chemical dynamics, environmental chemistry, trace detection; spacecraft structural mechanics, contamination, thermal and structural control; high temperature thermomechanics, gas kinetics and radiation; cw and pulsed chemical and excimer laser development, including chemical kinetics, spectroscopy, optical resonators, beam control, atmospheric propagation, laser effects and countermeasures.

Chemistry and Physics Laboratory: Atmospheric chemical reactions, atmospheric optics, light scattering, state-specific chemical reactions and radiative signatures of missile plumes, sensor out-of-field-of-view rejection, applied laser spectroscopy, laser chemistry, laser optoelectronics, solar cell physics, battery electrochemistry, space vacuum and radiation effects on materials, lubrication and surface phenomena, thermionic emission, photosensitive materials and detectors, atomic frequency standards, and environmental chemistry.

Electronics Research Laboratory: Microelectronics, solid-state device physics, compound semiconductors, radiation hardening; electro-optics, quantum electronics, solid-state lasers, optical propagation and communications; microwave semiconductor devices, microwave/millimeter wave measurements, diagnostics and radiometry, microwave/millimeter wave thermionic devices; atomic time and frequency standards; antennas, rf systems, electromagnetic propagation phenomena, space communication systems.

Materials Sciences Laboratory: Development of new materials: metals, alloys, ceramics, polymers and their composites, and new forms of carbon; nondestructive evaluation, component failure analysis and reliability; fracture mechanics and stress corrosion; analysis and evaluation of materials at cryogenic and elevated temperatures as well as in space and enemy-induced environments.

Space Sciences Laboratory: Magnetospheric, auroral and cosmic ray physics, wave-particle interactions, magnetospheric plasma waves; atmospheric and ionospheric physics, density and composition of the upper atmosphere, remote sensing using atmospheric radiation; solar physics, infrared astronomy, infrared signature analysis; effects of solar activity, magnetic storms and nuclear explosions on the earth's atmosphere, ionosphere and magnetosphere; effects of electromagnetic and particulate radiations on space systems; space instrumentation.